



CFD Modeling of Complex Chemical Processes: Multiscale and Multiphysics Challenges

Guest Editors:

Dr. Li Xi

Department of Chemical Engineering and School of Computational Science and Engineering, McMaster University, Hamilton, ON L8S 4L7, Canada

Dr. De-Wei Yin

The Dow Chemical Company, Midland, MI, USA

Dr. Jae Sung Park

Department of Mechanical and Materials Engineering, University of Nebraska-Lincoln, Lincoln, NE, USA

Deadline for manuscript submissions:

closed (31 August 2020)

Message from the Guest Editors

We cordially invite your contribution to this Special Issue, which will feature the latest developments in the CFD modeling and simulation of complex industrial processes in chemical and biological engineering, materials processing, advanced manufacturing, petroleum engineering, food and pharmaceutical processing, and other related areas. Contributions describing the application of CFD in chemical processes (either as a standalone tool or in combination with experiments and/or theory), development of new models involving CFD, innovations in numerical methods/algorithms, and the integration of CFD in the process design, control, and optimization are all welcome. Both original research and topical reviews will be considered (authors interested in contributing a review article are asked to discuss its topic scope with the Guest Editors as early as possible). Contributions that feature the methods or application of CFD for addressing the process scale-up challenge are particularly welcome.





an Open Access Journal by MDPI

Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and
Technology, University of Turin,
Via P. Giuria 9, 10125 Turin, Italy

Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Author Benefits

Open Access: free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility: indexed within Scopus, SCIE (Web of Science), Ei Compendex, Inspec, AGRIS, and other databases.

Journal Rank: JCR - Q2 (*Engineering, Chemical*) / CiteScore - Q2 (*Chemical Engineering (miscellaneous)*)

Contact Us

Processes Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland

Tel: +41 61 683 77 34
www.mdpi.com

mdpi.com/journal/processes
processes@mdpi.com
[X@Processes_MDPI](https://twitter.com/Processes_MDPI)